



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

September 5, 2025

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG731591008

LABORATORY GROWN DIAMOND

EMERALD CUT

11.61 X 7.65 X 5.39 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

5.01 CARATS

D

VVS 2

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

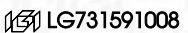
EXCELLENT

EXCELLENT

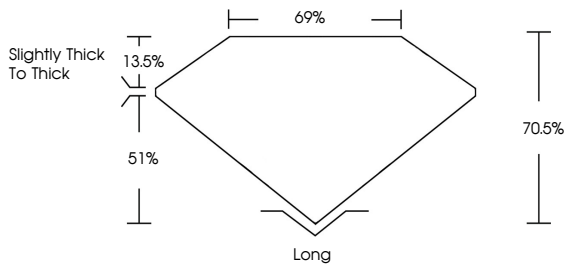
NONE

Inscription(s)

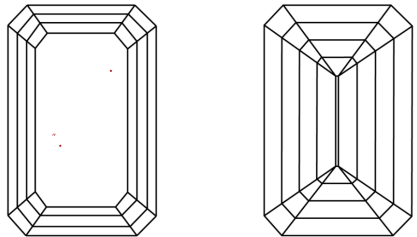
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

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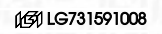
EXCELLENT

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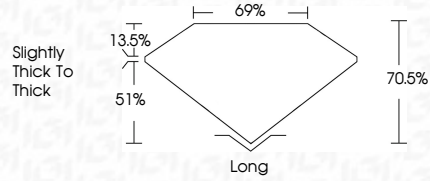
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PROPORTIONS



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5.01 CARATS

D

Carat Weight

Color Grade

Clarity Grade

Depth

Table

Graile

VVS 2

D

VVS 2

70.5%

69%

Slightly Thick To Thick

Long

EXCELLENT

EXCELLENT

NONE



Culet

Polish

Symmetry

Fluorescence

Inscription(s)

None

EXCELLENT

EXCELLENT

NONE



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